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Wontae Kim, Loida O. Casalme, Taiki Umezawa, Fuyuhiko Matsuda, Ryoichi Otomo, and Yuichi Kamiya*

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A reliable method to create adjacent acid-base pair sites on silica through hydrolysis of pre-anchored amide

Wontae Kim,¹ Loida O. Casalme,¹ Taiki Umezawa,² Fuyuhiko Matsuda,² Ryoichi Otomo,² Yuichi Kamiya*² ¹Graduate School of Environmental Science, Hokkaido University, Kita 10, Nishi 5, Kita-ku, Sapporo 060-0810, Japan ²Faculty of Environmental Earth Science, Hokkaido University, Kita 10, Nishi 5, Kita-ku, Sapporo 060-0810, Japan

E-mail: kamiya@ees.hokudai.ac.jp

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A method to create adjacent acid-base pair sites, which are carboxyl and amino groups, respectively, on silica through hydrolysis of pre-anchored amide is proposed. This ĩ method can produce an adjacent acid-base pair sites. The 4 5 catalyst showed excellent catalytic performance for aldol condensation of 4-nitrobenzaldehyde with acetone, 6 overwhelming the catalyst having only amino group and an 8 acid-base catalyst prepared in a conventional manner.

9 Keywords: Acid-base pair sites, Cooperative catalysis, 10 Aldol condensation

11 Because acid and base in a solution unavoidably 12 neutralize, they lose the acid and base functions and 13 generally do not work as an efficient acid or base catalyst in 14 the solution. On the other hand, some molecules having both 15 acidic and basic groups enhance the reaction rates in the solution.¹⁻⁴ Proline is the representative molecule and 16 efficiently promotes various carbon-carbon bond formation 17 18 reactions.^{5–7} It is pointed out that acidic and basic groups in 19 such molecules cooperatively work for the reactions. The 20 distance between acidic and basic groups in the molecule is important to determine the cooperative action as a catalyst. 21 In fact, synergetic effect arising from the acidic and basic 22 groups does not appear if they are placed away from each 23 24 other in the molecule.⁴ In other words, the molecule with the 25 adjacent acidic and basic groups, namely acid-base pair, often show higher catalytic performance than distantly 26 27 positioned analogs or those having either of the two.

28 In heterogeneous catalysts, some metal oxides 29 including Al₂O₃, ZnO, Al₂O₃-ZnO, and ZrO₂-ZnO have both 30 acid and base sites on the surface and they cooperatively promote the reactions.^{8–11} However, the distance between 31 32 the acid and base sites is widely distributed even for highly 33 crystalline metal oxides, since the surface of the metal oxides is inhomogeneous at atomic level. In addition, the 34 35 structure of the surface of the metal oxides is different 36 depending on the crystal faces and correspondingly the non-37 uniform distance between the acid and base sites is 38 unavoidable, while the distance is of critical importance to 39 exert the synergetic effect.

40 Immobilization of organosilane with a basic group on 41 metal oxides was proposed to control the distance between 42 acid and base sites as well as the density of them.¹²⁻¹⁵ 43 Immobilization of (3-aminopropyl)triethoxysilane on SiO₂ is a typical example to create the acid-base pair sites by this 44 approach, because silanol group on SiO2 acts as an acid 45 46 site.^{12,13} The acid and base sites formed by this approach 47 make the acid-base pair sites, working cooperatively, and 48 thus effectively promotes the carbon-carbon bond formation 49 reactions including aldol and Knoevenagel condensation

reactions.¹²⁻¹⁵ While silanol group on SiO₂ is weak Brønsted 50 51 acid site, the acid-base pair sites comprising strong one is created by using silica alumina¹⁶ and acidic 52 53 montmorillonite17 instead of SiO2. In addition to the 54 co-condensation immobilization approach, of 55 aminoalkylsilane with tetraethyl orthosilicate has been 56 extensively studied to synthesize the siliceous solids having the acid-base pair sites on the surface.18 57

58 As alternative approaches, acid-base pair sites on the 59 surface can be created by the immobilizations of two different organosilanes on metal oxides or the co-60 condensation of the two.¹⁹⁻²⁶ This has a great advantage for 61 62 installation of a variety of acid and base sites by simply changing acid and base attached to organosilanes.^{21,23,24,26-28} 63 64 However, the acidic and basic groups in silanes should be 65 protected or silanes should have functional groups that are transformable to acidic and basic groups but not interactive 66 each other to avoid neutralization during 67 the synthesis, 19,21,22,27,28 requiring burdensome experimental 68 69 processes to obtain the acidic and basic sites for the 70 synthesis. In addition, this approach gives the randomly 71 located acid and base sites, since no strong interaction 72 works between the two reagents. Therefore, in this approach, 73 it is hard to create a single acid-base pair sites with 74 prescribed distance that exert the synergetic effect on 75 catalysis.

Step 1. Amide synthesis



97 Figure 1. Synthetic procedure for adjacent acid-base pair 98 sites on SiO₂ by use of hydrolysis of pre-anchored amide. 99

In the present study, we wish to propose a reliable 1 2 method to definitely create adjacent acid-base pair sites on 3 the surface through hydrolysis of secondary amide 4 immobilized on SiO2. In the method, the amide with 5 trialkoxysilyl groups at both ends is immobilized on SiO₂ 6 and subsequently is hydrolyzed to create the adjacent 7 carboxyl and amino groups, namely the acid-base pair sites 8 (Figure 1). The method has a great advantage to create only 9 adjacent acid-base pair sites in principle. We furthermore demonstrate that the prepared catalyst exhibits excellent 10 11 catalytic performance for aldol condensation.

12 5-(triethoxysilyl)pentanoic 3acid 13 (triethoxysilyl)propylamide (1) was synthesized from 3-14 amino-1-propene and 4-pentenoic acid by condensation, 15 followed by hydrosilylation with triethoxysilane (Steps 1 16 and 2 in Figure 1). Structure and purity of 1 were confirmed by ¹H and ¹³C solution NMR (Figure S1). Immobilization of 17 1 on SiO₂ (Nippon Aerosil Co., Ltd., AEROSIL[®] 300, 300 18 19 $m^2 g^{-1}$) was performed in toluene at reflux temperature for 20 24 h (Step 3 in Figure 1). To prevent multi-layer deposition 21 of 1 on SiO₂, the density of 1 on SiO₂ was adjusted to 0.4 22 nm^{-2} with consideration for the molecular size of 1. The 23 obtained material is denoted as Amide/SiO2. The IR 24 spectrum of Amide/SiO₂ showed absorption bands 25 assignable to amide at 1524 and 1652 cm⁻¹ and methylene groups at $2800 - 2900 \text{ cm}^{-1}$ (Figure 2(b) and 2(d)). The 26 27 molar ratio of carbon to nitrogen (=C/N) determined by 28 CHN elemental analysis for Amide/SiO2 was 8.14 (Table 29 S1), indicating that almost all ethoxy groups in 1 were 30 eliminated by the reaction with silanol groups on SiO₂ to form Si-O-Si bonds. In fact, the decrease of silanol group on 31 32 SiO₂ was confirmed as a sharp and intense negative band at 33 3740 cm⁻¹ in the difference IR spectrum before and after the 34 immobilization (Figure 2(d)). ${}^{13}C{}^{1}H{}$ CP/MAS NMR 35 spectrum of Amide/SiO₂ was almost identical to ¹³C solution NMR spectrum of 1 except for weakened peaks due 36 37 to ethoxy group (Figure S2). These results demonstrated that 38 1 was successfully immobilized on SiO₂ as illustrated in 39 Figure 1.



Figure 2. IR spectra for pristine (a) SiO₂, (b) Amide/SiO₂,
(c) Acid-Base/SiO₂, and difference spectra obtained by (d)
b-a, (e) c-a, and (f) c-b.

60 Finally, amide bond in Amide/SiO2 was hydrolyzed in 61 hydrochloric acid (6 mol L⁻¹) at reflux temperature for 12 h 62 to form carboxyl and amino groups (Step 4 in Figure 1). The 63 obtained material is denoted as Acid-Base/SiO2. The amount 64 of Cl remaining in Acid-Base/SiO2 was below detection 65 limit for elemental analysis. In the IR spectrum of Acid-66 Base/SiO₂, the absorption bands due to amide group were 67 absent and instead, two new ones assignable to N-H 68 deformation vibration of amino group and C=O stretching 69 vibration of carboxyl one arose at 1592 and 1730 cm⁻¹, 70 respectively (Figure 2(c) and 2(f)), which were identical to 71 those observed for the samples in which each of 5-72 (triethoxysilyl)pentanoic acid and (3-73 aminopropyl)triethoxysilane was fixed on SiO₂ (Figure S3). 74 The cleavage of amide bond was also confirmed by the peak 75 shift of carbonyl group from 176.6 to 182.3 ppm in ${}^{13}C{}^{1}H{}$ 76 CP/MAS NMR spectra (Figure S2). There was no substantial shift in the other peaks in ¹³C{¹H} CP/MAS 77 78 NMR spectra with the hydrolysis. In addition, the contents 79 of carbon and nitrogen as well as the C/N ratio for Acid-80 Base/SiO₂ were almost the same as those for Amide/SiO₂ 81 (Table S1). Therefore, it was concluded that Acid-Base/SiO₂ 82 was successfully synthesized as Figure 1 shows.

83 Next, we evaluated the catalytic performance of Acid-84 Base/SiO₂ for aldol condensation of 4-nitrobenzaldehyde 85 with acetone and compared to the catalysts with only carboxyl (Acid/SiO₂) or amino group (Base/SiO₂). 86 Acid/SiO₂ and Base/SiO₂ were prepared by the 87 modifications of SiO₂ with 5-(triethoxysilyl)pentanoic acid 88 89 and (3-aminopropyl)triethoxysilane, respectively, in a 90 similar manner to that for Amide/SiO₂ (Details are shown in 91 Supporting Information).

92 Base/SiO₂ showed catalytic activity for the aldol 93 condensation reaction and the conversion at 24 h was 34% 94 (Entry 3 in Table 1), while pristine SiO₂ (Entry 1) and 95 Acid/SiO₂ (Entry 2) were completely inactive, indicating that the basic sites catalyzed the reaction as is reported.²⁹ In 96 97 the experiment, we used Base/SiO₂ with the amino group 98 density of 0.8 nm⁻², because it showed the highest catalytic 99 activity among them with the various densities ranging from 100 0.1-2 nm⁻². To confirm the synergetic effect by silanol 101 group on SiO₂ as an acid site, we carried out the reaction 102 Base/SiO₂ over treated with 1,1,1,3,3,3hexamethyldisilazane to cap remaining silanol group with 103 104 trimethylsilyl group (Base/SiO₂(TMS)) and the conversion 105 was only 9% (Entry 4), indicating that synergetic effect 106 between the amino group and silanol on SiO₂ was present 107 for Base/SiO₂. Amide/SiO₂ did not show any activity (Entry 108 5). It should be noted that Acid-Base/SiO₂ efficiently 109 promoted the reaction and the conversion for Acid-110 Base/SiO₂ was much higher than that for Base/SiO₂ despite 111 no difference in the number of the basic sites (Entry 6). We 112 further confirmed that Acid-Base/SiO2 with the density of 113 0.4 nm⁻², which was used here, was the most active catalyst 114 among them with various acid-base pair site densities. 115 Equimolar physical mixture of Acid/SiO2 and Base/SiO2 gave only low conversion (Entry 7). Therefore, we conclude 116 117 that the adjacency of carboxyl group to amino one created

by hydrolysis of the amide resulted in the excellent catalytic 1 2 activity of Acid-Base/SiO₂ for the reaction.

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4 Table 1. Comparison of catalytic activities for aldol 5 condensation of 4-nitrobenzaldehvde with acetone.

Entry	Catalyst	Conv.ª/%
1	SiO ₂	0
2	Acid/SiO ₂	0
3	Base/SiO ₂	34
4	Base/SiO ₂ (TMS)	9
5	Amide/SiO ₂	0
6	Acid-Base/SiO ₂	66 (61, 63) ^b
7	$Acid/SiO_2 + Base/SiO_2$	8
8	Acid-Base(CV)/SiO ₂	42
9	Propylamine ^c	22
10	Propylamine + Pentanoic acid ^d	12

Reaction conditions: 4-nitrobenzaldehyde, 0.5 mmol; acetone, 6 1.5 mmol; catalyst, 0.025 mmol; toluene (solvent), 10 mL; 8 temperature, 50°C; time, 24 h. The amount of the catalyst was g defined according to the number of base sites estimated by 10 titration. In entries 1 and 2, 0.05 g of the catalysts were used. In entry 5, 0.10 g of the catalyst was used. a Conversion of 4-11 nitrobenzaldehyde. ^bThe data in parenthesis are the conversions 12 13 for 1st and 2nd reuses. Homogeneous catalyst. Mixture. 14

15 At 10 h for the reaction over Acid-Base/SiO2, the catalyst was removed by filtration and the obtained solution 16 was further heated again at 50°C. No significant increase in 17 18 the conversion was observed (Figure 3), indicating that the 19 reaction proceeded over Acid-Base/SiO2. In addition, Acid-20 Base/SiO₂ was reusable for the reaction. After the reaction 21 for 24 h, the catalyst was collected by a centrifugation and 22 washed with toluene and ethanol, followed by drying at 23 60°C overnight. Then, the catalyst was afforded to the 24 second reaction under the same reaction conditions. It was 25 found that Acid-Base/SiO₂ was reusable without any 26 significant loss of activity for at least 2 times reuse (Entry 6 27 in Table 1).



39 Figure 3. Hot-filtration experiment for the aldol 40 condensation over Acid-Base/SiO₂. (•) without removal of 41 the catalyst and (\circ) the catalyst was removed at 10 h. 42

43 To highlight the superiority of our proposed method, 44 we further compared Acid-Base/SiO2 with another acid-base SiO₂ catalyst (Acid-Base(CV)/SiO₂) that was prepared by a 45 conventional manner^{25,26} and a homogeneous base catalyst. 46 47 Acid-Base(CV)/SiO₂ was prepared by immobilizing tert-48 butoxycarbonyl (Boc)-protected 3-49 (triethoxysilyl)propylamine and 5-(triethoxysilyl)pentanoic

acid on SiO₂, followed by deprotection of Boc to give the 50 51 catalyst that had both acid and base sites (Details are shown 52 in Supporting Information). Acid-Base(CV)/SiO₂ was less 53 active than Acid-Base/SiO₂ (Entry 8), while the number of 54 the base sites for Acid-Base(CV)/SiO₂ determined by 55 titration (0.16 mmol g^{-1}) was almost the same as that for 56 Acid-Base/SiO₂ (0.14 mmol g^{-1}). We presumed that the low 57 activity of Acid-Base(CV)/SiO₂ was due to the presence of 58 the less active amino group that was not adjacent to 59 carboxylic acid. In other word, our proposed method can 60 create efficiently the adjacent acid-base pair sites showing the high catalytic activity. Jones and co-workers reported 61 that the modification of Base/SiO₂ with methacrylic acid, 62 63 which was formed by deprotection of tert-butylmethacrylate 64 fixed in advance, to make acid-base pair sites lower the 65 catalytic activity for the aldol condensation²² unlike Acid-Base(CV)/SiO₂. The carboxyl group in Acid-Base(CV)/SiO₂ 66 67 is more flexible than that in their catalyst because of the 68 longer (C_4) methylene chain, which probably makes the 69 distance of acid-base pair sites appropriate for the activation 70 of the reactants. It is interesting that the adjacent acid-base 71 pair sites on Acid-Base/SiO2 was more active than the corresponding propylamine (Entry 9) that acted as a 72 73 homogenous catalyst and a mixture of propylamine and 74 pentanoic acid (Entry 10).

75 In the aldol condensation catalyzed by primary amine, 76 it is proposed based on the spectroscopic analyses with IR, 77 Raman and ¹³C CP/MAS NMR that the reaction proceeds 78 through the formation of enamine intermediate between ketone and amine,^{30,31} while imine formation inhibits the 79 80 reaction.³¹ In this process, it is assumed that enough 81 nucleophilicity of amine is required for the addition to 82 carbonyl group. Thus, higher the nucleophilicity of amine 83 on the catalyst is, more the reaction is enhanced. To get 84 information on the nucleophilicity, we measured N 1s XPS 85 spectra for Base/SiO₂ and Acid-Base/SiO₂ (Figure S4). The 86 both catalysts gave the peaks with almost the same binding 87 energy, indicating similar nucleophilicity between Acid-88 Base/SiO2 and Base/SiO2 having no carboxyl group for 89 neutralization of amino group.



107 Figure 4. Plausible mechanism for the acceleration of aldol 108 condensation over the adjacent acid-base pair sites on SiO₂.

1 2 The other possibility is that the acid and base sites on 3 Acid-Base/SiO₂ cooperatively activate the reactants (Figure 4).^{30,31} In acid-base cooperative mechanism for the aldol 4 5 condensation, an enamine derived from acetone and amino 6 group in Acid-Base/SiO₂ is first generated by the assistance 7 of carboxyl group. Subsequently, nucleophilic addition of 8 the enamine to the aldehvde smoothly occurs through 9 activation of the aldehyde by the carboxyl group to form the carbon-carbon bond. Under these processes, the higher 10 acidity of the carboxyl group than the silanol and the 11 appropriate adjacency between the carboxyl and amino 12 groups are thought to be important for the potent catalytic 13 activity of Acid-Base/SiO2. We are now investigating 14 kinetic and spectroscopic studies to reveal how the acid-15 base pair sites on Acid-Base/SiO₂ catalyze the reaction and 16 thus will report them in the near future. 17

18 In conclusion, we have shown the excellent catalytic 19 performance of the present catalyst having adjacent acidbase pair sites for the aldol condensation of 4-20 21 nitrobenzaldehyde with acetone. The acid-base pair was 22 closely arranged by hydrolysis of amide immobilized on 23 SiO₂, exhibiting much higher catalytic activity than other 24 catalysts examined such as only acid or base sites on SiO₂. 25 This method enabled close proximity between acid and base and further applicable to create acid-base pair sites with 26 27 precisely controlled distance by hydrolysis of amide 28 including linker moiety. (Figure S5) 29

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34 Supporting Information is available on https://doi.org/??????? 35

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